

# (12) International Application Status Report

**Received at International Bureau:** 23 August 2018 (23.08.2018)

**Information valid as of:** 31 October 2018 (31.10.2018)

**Report generated on:** 16 September 2019 (16.09.2019)

**(10) Publication number:**

WO2019/045953

**(43) Publication date:**

07 March 2019 (07.03.2019)

**(26) Publication language:**

English (EN)

**(21) Application Number:**

PCT/US2018/045346

**(22) Filing Date:**

06 August 2018 (06.08.2018)

**(25) Filing language:**

English (EN)

**(31) Priority number(s):**

15/691,696 (US)

**(31) Priority date(s):**

30 August 2017 (30.08.2017)

**(31) Priority status:**

Priority document received (in compliance with PCT Rule 17.1)

**(51) International Patent Classification:**

**H01L 23/16** (2006.01); **H01L 21/683** (2006.01); **H01L 23/31** (2006.01)

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**(54) Title (EN):** MOLDED DEVICE PACKAGE WITH AIR CAVITY

**(54) Title (FR):** EMBALLAGE DE DISPOSITIF MOULÉ AVEC CAVITÉ À AIR

**(57) Abstract:**

**(EN):** Conventional packages for 5G applications suffer from disadvantages including high mold stress on the die, reduced performance, and increased keep-out zone. To address these and other issues of the conventional packages, it is proposed to pre-apply a wafer-applied material, which remains in place, to form an air cavity between the die and the substrate. The air cavity can enhance the dies performance. Also, since the wafer-applied material can remain in place, the keep-out zone can be reduced. As a result, higher density modules can be fabricated.

**(FR):** Les boîtiers classiques pour des applications 5G souffrent d'inconvénients comprenant une contrainte de moule élevée sur la puce, une performance réduite et une zone de conservation accrue. Pour résoudre ces problèmes et d'autres problèmes des boîtiers classiques, il est proposé de pré-appliquer un matériau appliqué en tranche, qui reste en place, pour former une cavité d'air entre la puce et le substrat. La cavité d'air peut améliorer les performances de la puce. De plus, étant donné que le matériau appliqué à la tranche peut rester en place, la zone de maintien peut être réduite. Par conséquent, des modules de densité supérieure peuvent être fabriqués.

**International search report:**

Received at International Bureau: 29 October 2018 (29.10.2018) [EP]

**International Report on Patentability (IPRP) Chapter II of the PCT:**

Not available

**(81) Designated States:**

AE, AG, AL, AM, AO, AT, AU, AZ, BA, BB, BG, BH, BN, BR, BW, BY, BZ, CA, CH, CL, CN, CO, CR, CU, CZ, DE, DJ, DK, DM, DO, DZ, EC, EE, EG, ES, FI, GB, GD, GE, GH, GM, GT, HN, HR, HU, ID, IL, IN, IR, IS, JO, JP, KE, KG, KH, KN, KP, KR, KW, KZ, LA, LC, LK, LR, LS, LU, LY, MA, MD, ME, MG, MK, MN, MW, MX, MY, MZ, NA, NG, NI, NO, NZ, OM, PA, PE, PG, PH, PL, PT, QA, RO, RS, RU, RW, SA, SC, SD, SE, SG, SK, SL, SM, ST, SV, SY, TH, TJ, TM, TN, TR, TT, TZ, UA, UG, US, UZ, VC, VN, ZA, ZM, ZW

European Patent Office (EPO) : AL, AT, BE, BG, CH, CY, CZ, DE, DK, EE, ES, FI, FR, GB, GR, HR, HU, IE, IS, IT, LT, LU, LV, MC, MK, MT, NL, NO, PL, PT, RO, RS, SE, SI, SK, SM, TR

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Eurasian Patent Organization (EAPO) : AM, AZ, BY, KG, KZ, RU, TJ, TM

### **Declarations:**

Declaration made as applicant's entitlement, as at the international filing date, to apply for and be granted a patent (Rules 4.17(ii) and 51bis.1(a)(ii)), in a case where the declaration under Rule 4.17(iv) is not appropriate

Declaration made as applicant's entitlement, as at the international filing date, to claim the priority of the earlier application, where the applicant is not the applicant who filed the earlier application or where the applicant's name has changed since the filing of the earlier application (Rules 4.17(iii) and 51bis.1(a)(iii))